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To:	Examiner Sara W. Crane	From:	Timothy N. Trop
Company:	US Patent Office	Date:	January 5, 2006
Fax:	(571) 273-8300	Pages:	6 (including cover sheet)
Your Re:	10/622,955	Our Ref:	TL1021US

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Applicant:	Justin K. Brask et al.	§	Art Unit:	2811
Serial No.:	10/622,955	§	Examiner:	Sara W. Crane
Filed:	July 18, 2003	§	Atty Docket:	ITL1021US P16708
For:	Etching Metal Silicides and Germanides	§	Assignee:	Intel Corporation

Mail Stop AF
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

SUPPLEMENTAL REPLY TO FINAL REJECTION

Sir:

As a supplemental response to the final rejection, please amend the above-referenced patent application as follows:

Date of Deposit: January 5, 2006
I hereby certify that this correspondence is being facsimile
transmitted to the United States Patent and Trademark Office
(Fax No. 571/273-8300) on the date indicated above.
Cynthia L. Hayden
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